Supporting Information for:

Selective Formation of Latticed-Nanostructure with precise alignment of DNA-templated Gold Nanowires

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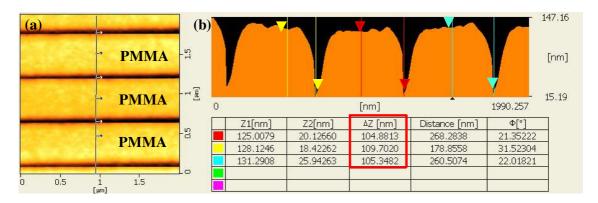


Figure S1. AFM image for PMMA patterned using electron beam lithography process: (a) image of the patterned PMMA; (b) scan profile along the line in image (a).